

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Ramkumar SUBRAMANIAN, et al.
Title: TWO MASK PHOTORESIST EXPOSURE PATTERN
FOR DENSE AND ISOLATED REGIONS
Appl. No.: Unassigned
Filing Date: 06/25/2001
Examiner: Unassigned
Art Unit: Unassigned



**TRANSMITTAL LETTER FOR
PROPRIETARY INFORMATION DISCLOSURE STATEMENT
UNDER 37 CFR 1.56 AND MPEP §§ 742 AND 724.02**

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

Attached hereto is a Proprietary Information Disclosure Statement submitting proprietary information to the Patent and Trademark Office in accordance with the requirements of 37 C.F.R. § 1.56 and MPEP §724. Applicant respectfully requests that the information be considered only by the Examiner in charge of the above-caption application, or other authorized Patent and Trademark Office employee.

Respectfully submitted,

Date June 25, 2001

FOLEY & LARDNER
Washington Harbour
3000 K Street, N.W., Suite 500
Washington, D.C. 20007-5109
Telephone: (202) 672-5407
Facsimile: (202) 672-5399

By Reg No 43445

David A. Blumenthal
Attorney for Applicant
Registration No. 26,257

PROPRIETARY MATERIAL NOT OPEN TO PUBLIC.
TO BE OPENED ONLY BY EXAMINER OR OTHER AUTHORIZED
PATENT AND TRADEMARK OFFICE EMPLOYEE



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO. 039153/0381

In re Patent Application of:

Ramkumar SUBRAMANIAN et al.

Serial No.: Unassigned

Group Art Unit: Unassigned

Filed: June 25, 2001

Examiner: Unassigned

For: TWO MASK PHOTORESIST EXPOSURE PATTERN FOR DENSE AND ISOLATED
REGIONS

PROPRIETARY INFORMATION DISCLOSURE STATEMENT
UNDER 37 CFR 1.56 AND MPEP §§ 724.02 AND 724.04

Commissioner for Patents
Washington, D.C. 20231

Sir:

The following is a listing of a copending U.S. patent applications which relate to the
above-identified application.

<u>Attorney Docket Number</u>	<u>Serial No.</u>	<u>Filing Date</u>	<u>Inventors</u>	<u>Group Art Unit</u>
039153/0389	09/716,218	11/21/2000	Todd Lukanc	1756
039153/0390	09/790,537	2/23/2001	Todd Lukanc, Christopher F. Lyons	2822

Applicants assume that the Examiner will have access to all of the references cited
in the co-pending applications. However, if the Examiner wishes applicants to submit
copies of each of the references cited in the co-pending applications, the Examiner is
requested to inform the applicants. Applicants consider the aforementioned documents and
the disclosure of their existence as pending applications to constitute proprietary

information. Accompanying this Proprietary Information Disclosure Statement is a transmittal letter indicating that the materials contained herein are proprietary, as required by MPEP § 724.02.

TIMING OF THE DISCLOSURE AND FEE

The instant Information Disclosure Statement is being filed in compliance with 37 C.F.R. §1.97(c) before the mailing of an office action and therefore no fee is required.

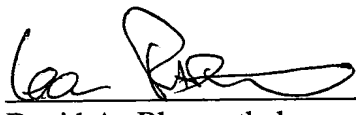
Applicants respectfully request that the Examiner considers the foregoing information and provide in the next official communication the information set forth in MPEP § 724.04(a), so that the applicants can, if appropriate, subsequently file a petition to expunge those materials, as provided according to MPEP § 724.05.

Respectfully submitted,

June 25, 2001

Date

FOLEY & LARDNER
3000 K Street, N.W., Suite 500
Washington, D.C. 20007-5109
Tel: (202) 672-5300
Fax: 202-672-5399


for David A. Blumenthal
Reg. No. 26,257

Ag No 43,445

THE COMMISSIONER IS HEREBY AUTHORIZED TO CHARGE ANY DEFICIENCY OR CREDIT ANY OVERPAYMENT TO DEPOSIT ACCOUNT NO. 19-0741.